WEST Search History

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DATE: Monday, December 27, 2004

Hide?	Set Name	Query	Hit Coun
		DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=OR	
☐	L5	(silicon adj source adj gas) and (nitrogen adj source adj gas) and (oxygen adj source adj gas)	
☐	L4	(silicon adj oxide adj layer) and L3	
☐	L3	nitride and oxide and ammonia and PECVD and (remote adj plasma)	1
☐	L2	nitride and oxide and ammonia and PECVD and (remote adj plasma)	1
☐	L1	(source adj gas) and (semiconductor adj device) and (ammonia) and oxide and nitride and (dual with spacer$1)	

END OF SEARCH HISTORY

h   e b   b cg b chh   e g   hc   f ff e ch   e   e e